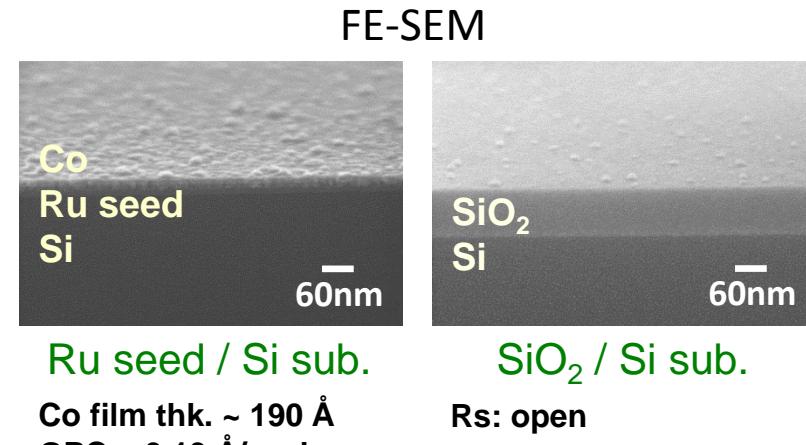
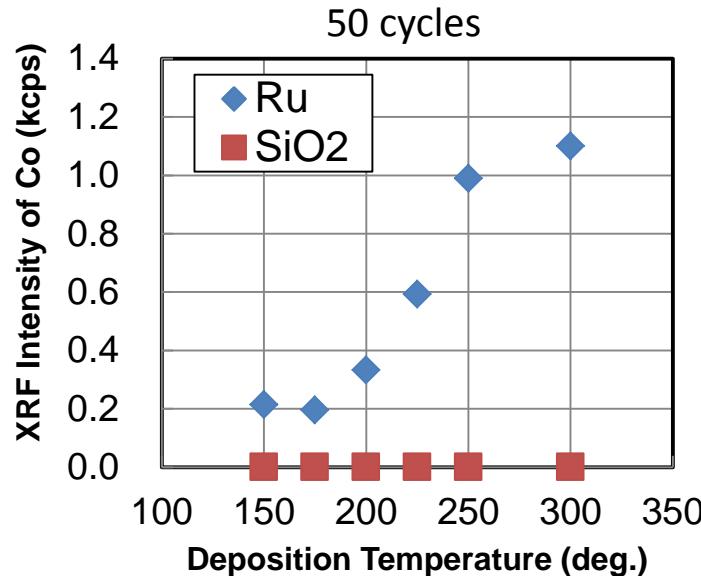
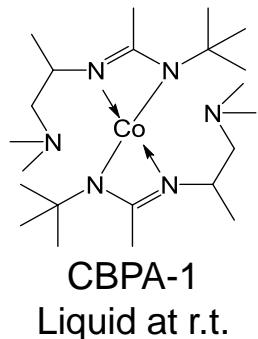
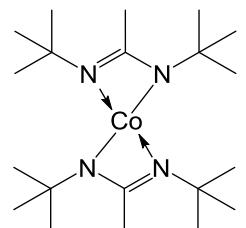


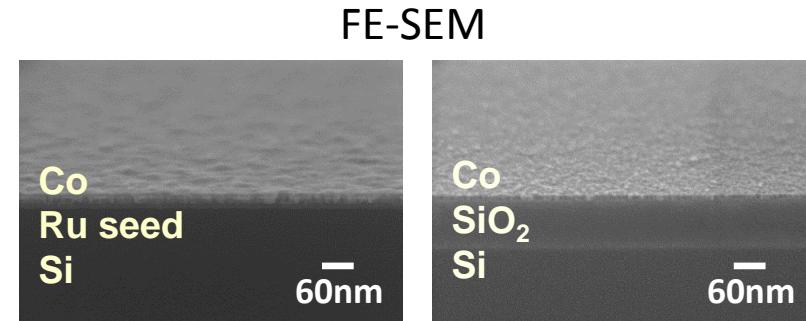
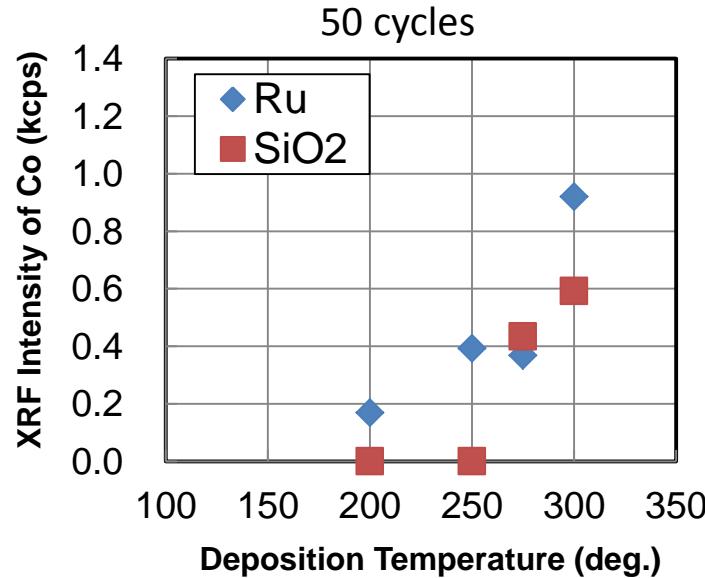
Co precursor + H₂ Thermal-ALD, Ru and SiO₂ substrates



➤ CBPA-1 has much better selectivity.



Ref.: Co(tBuAMD)₂
Melting point: 103°C



➤ Co(tBuAMD)₂ shows no selectivity.